



ocket No.: 49657-947

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

: **RESPONSE UNDER 37 CFR 1.116**

: **EXPEDITED PROCEDURE**

Yoshikazu NAGAMURA, et al.

: Customer Number: 20277

: Confirmation Number: 6590

Serial No.: 09/779,839

: Group Art Unit: 1746

Filed: February 09, 2001

: Examiner: M. Kornakov

For: **METHOD OF AND APPARATUS FOR WASHING PHOTOMASK AND WASHING SOLUTION FOR PHOTOMASK**

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RESPONSE AFTER FINAL

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The following remarks are submitted in response to the Final Office Action dated May 20, 2003.

REMARKS

Claims 1-7 and 15 are pending.

THE DOUBLE PATENTING REJECTION

Claims 1-7 and 15 were rejected on the grounds of obviousness-type double patenting over claims 10 and 11 of U.S. Patent No. 6,277,205.